Appendix D

Contour plots of the optimal recipe for

the CCF design

In this appendix the completed contour plots of the optimal recipe for the CCF design have provided here.

SS

0.0785554

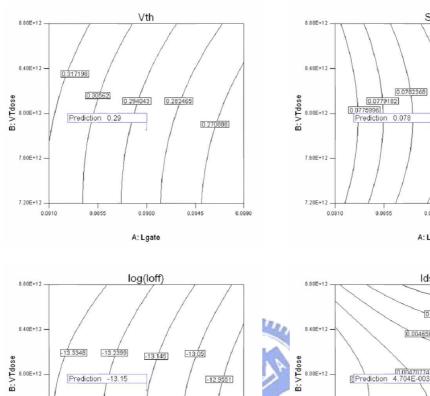
0.0900

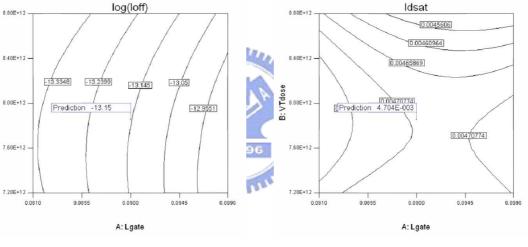
A: Lgate

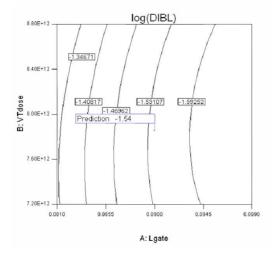
0.078874

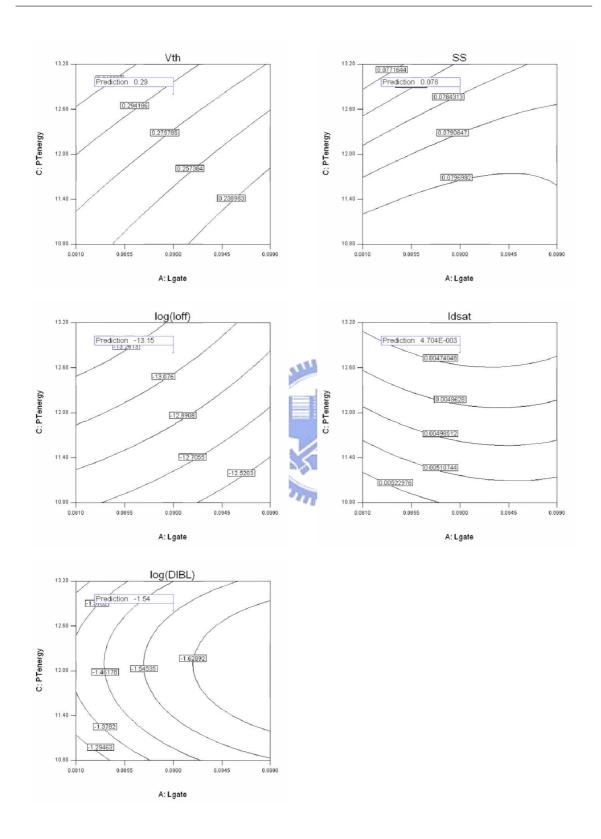
0.0945

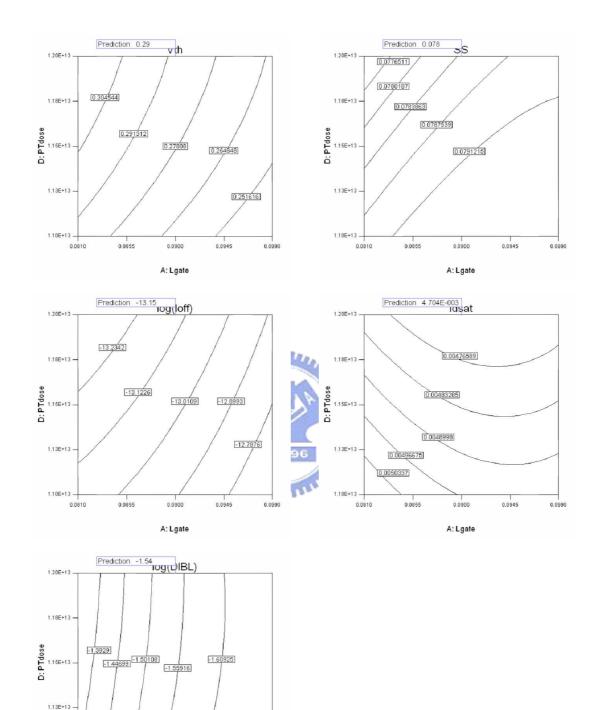
0.0990











0.0945

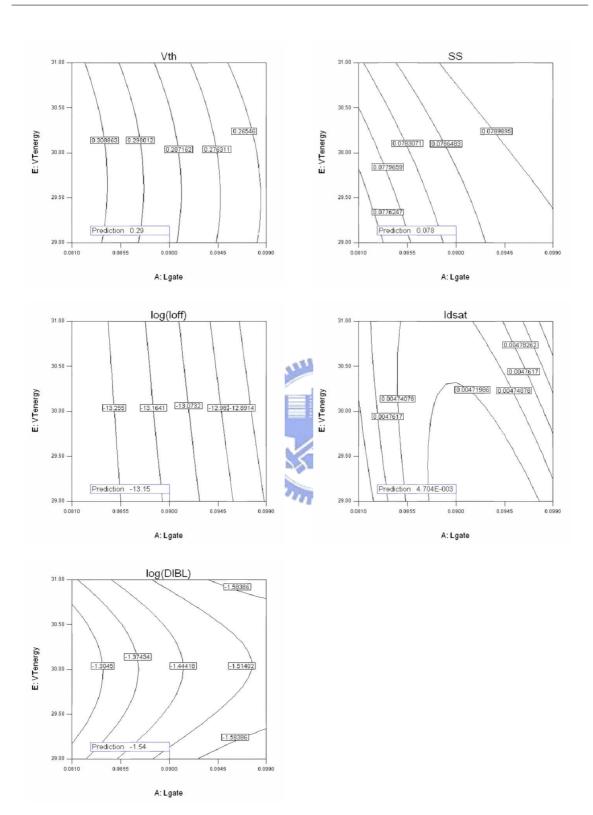
0.0990

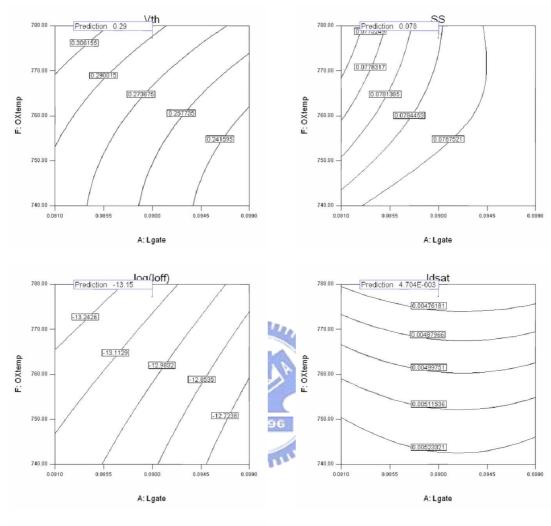
1.10E+13 -

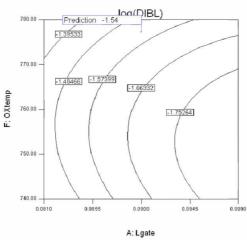
0.0810

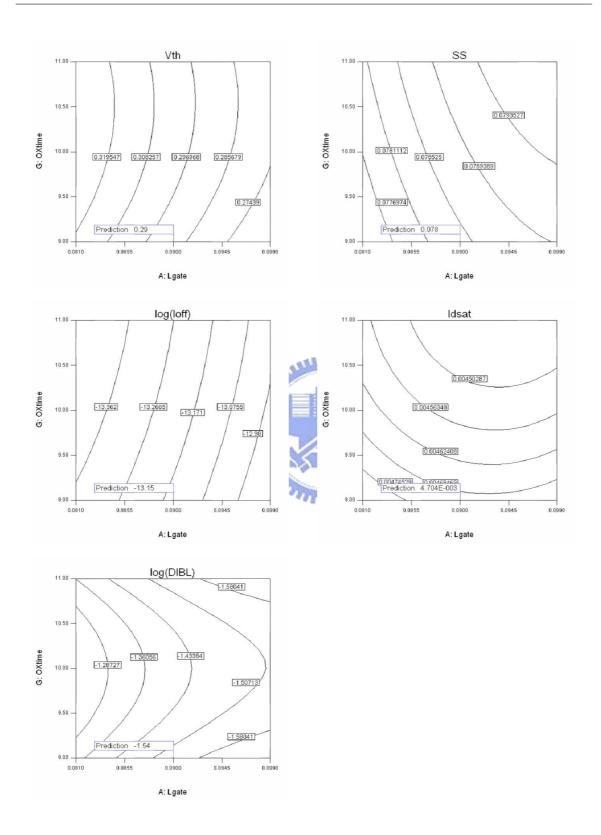
0.0855

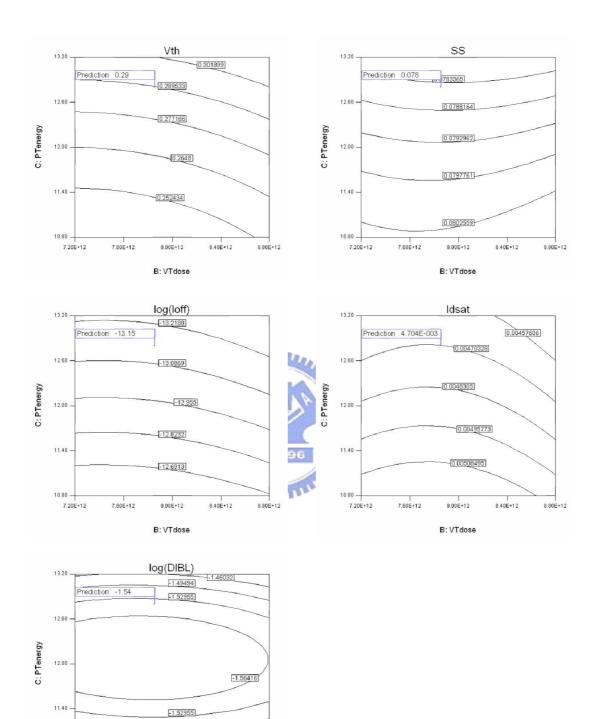
A: Lgate











-1.49494

8.00E+12

B: VTdose

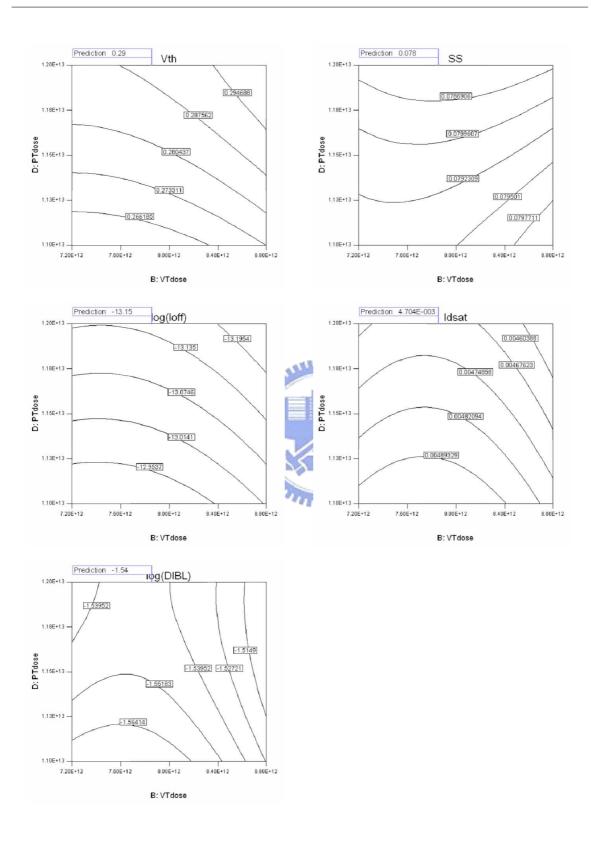
7.20E+12

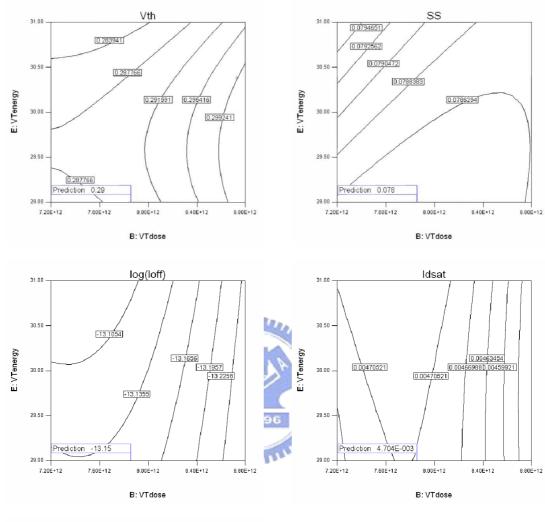
7.60E+12

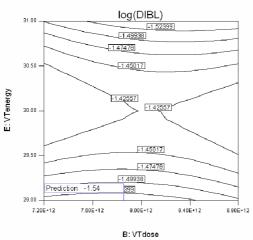
-1.46032 -1.42571

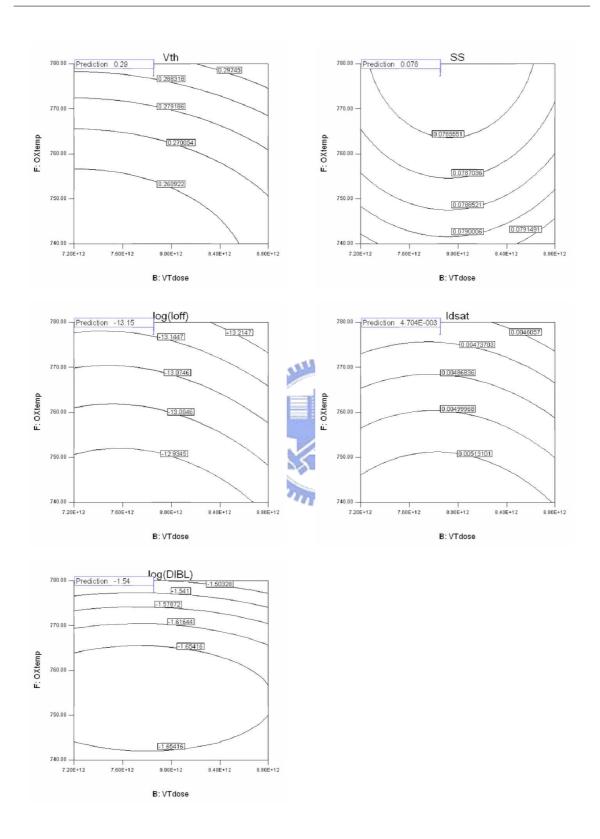
8.40E+12

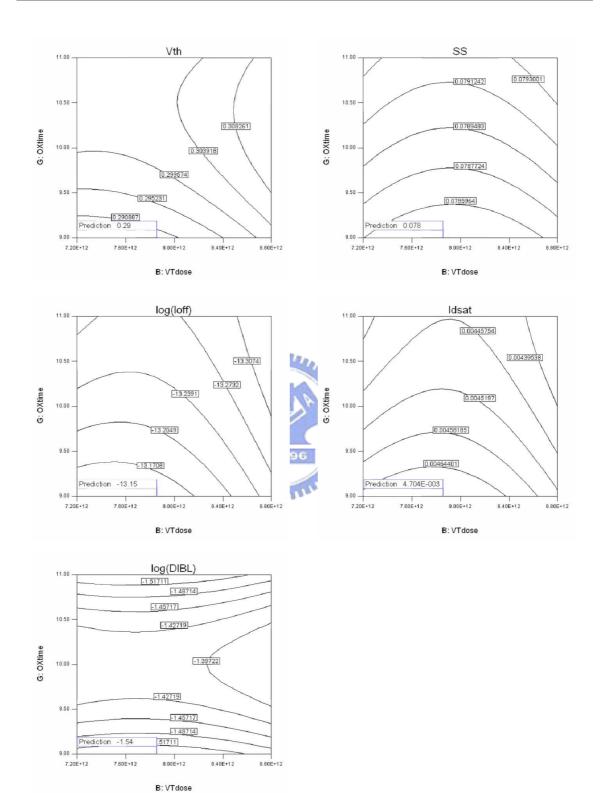
8.80E+12

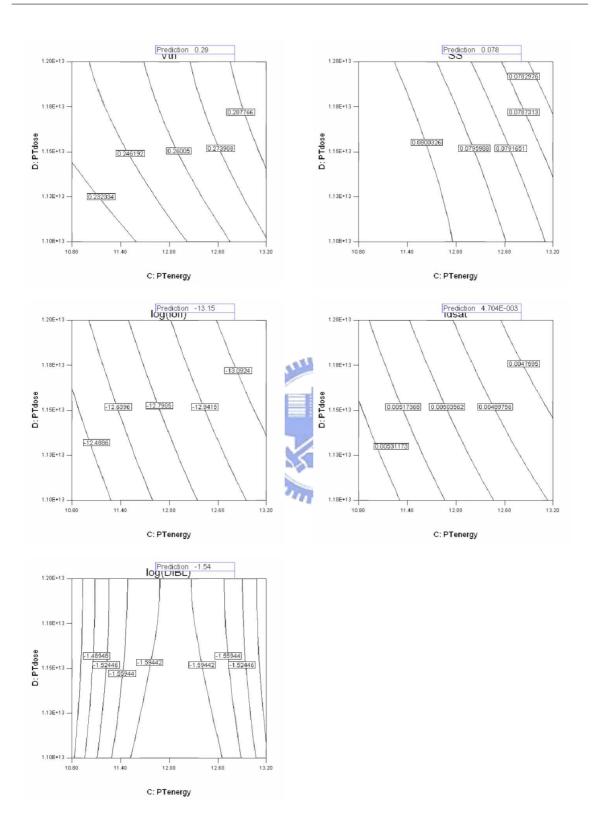


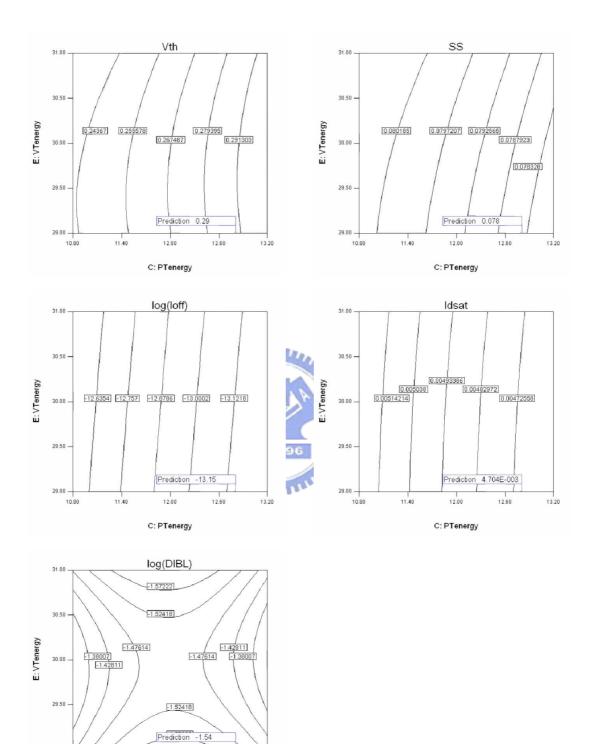












29.00

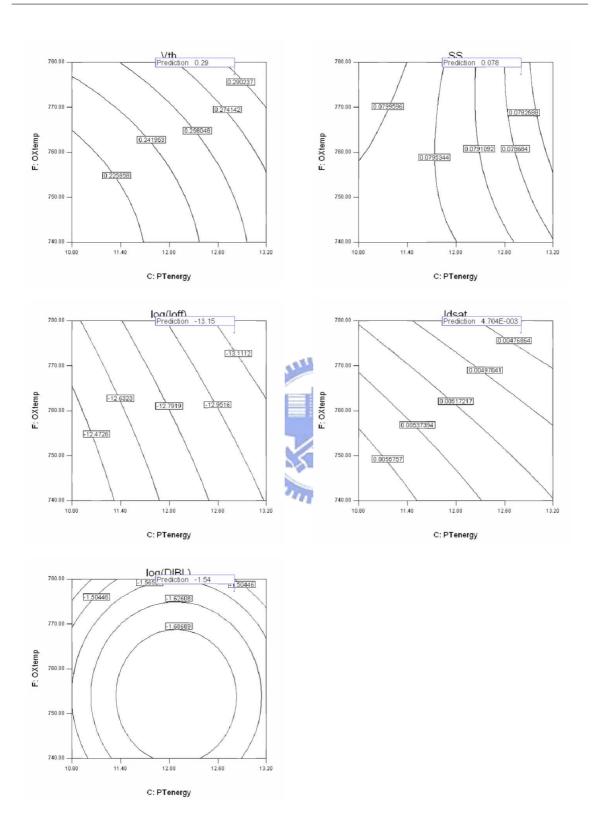
10.80

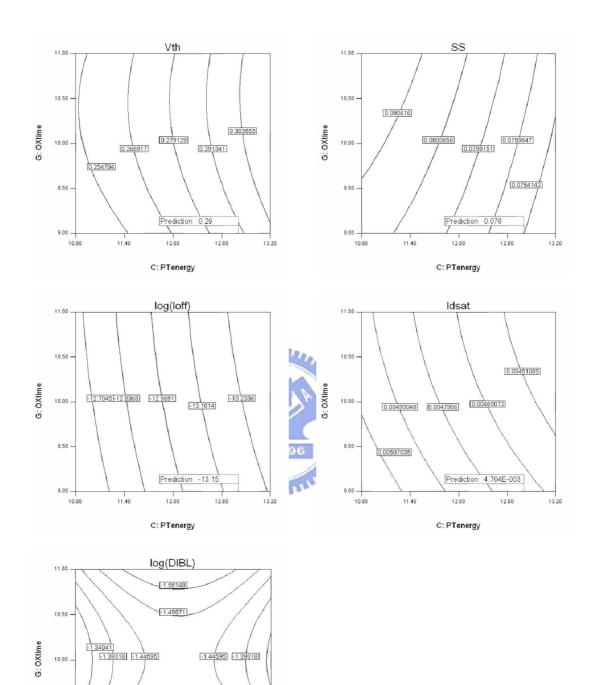
11.40

C: PTenergy

12.60

13.20





-1.49871

____-1.55148] Prediction -1.54

12.00

C: PTenergy

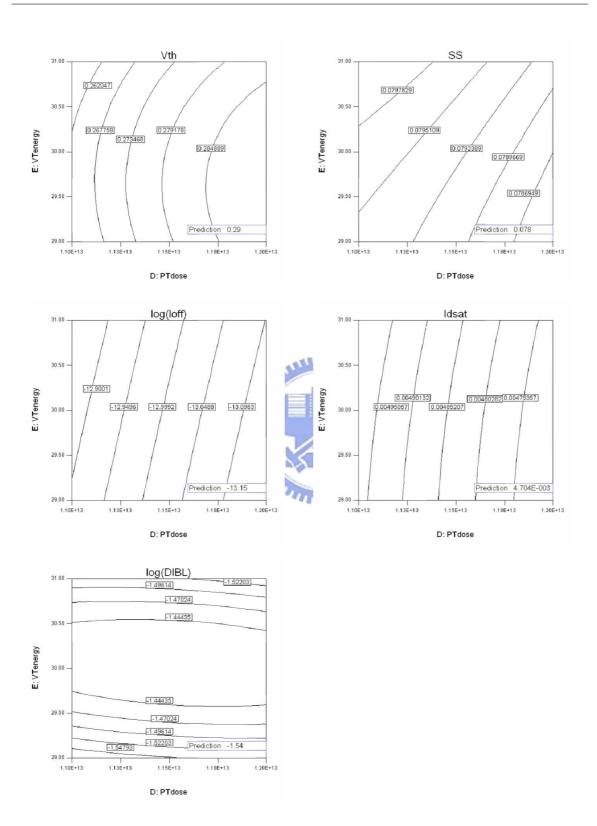
11.40

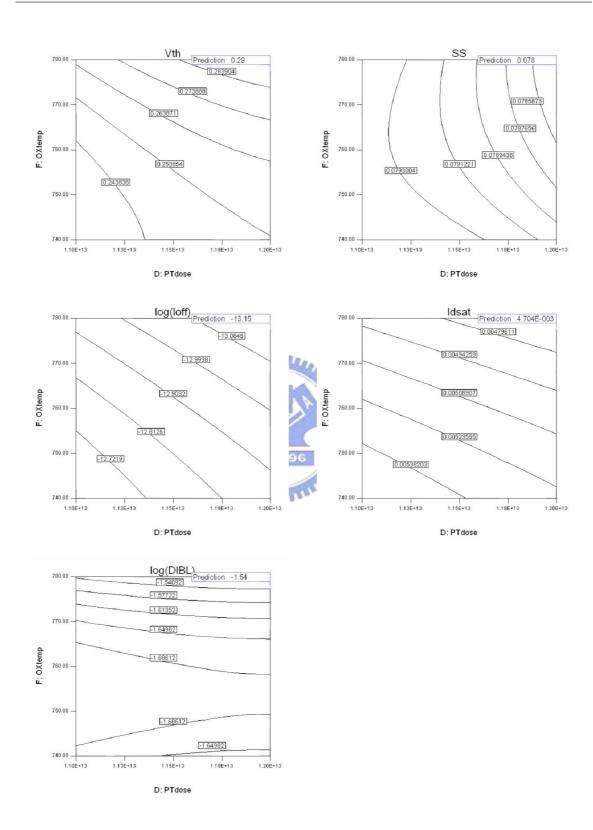
12.60

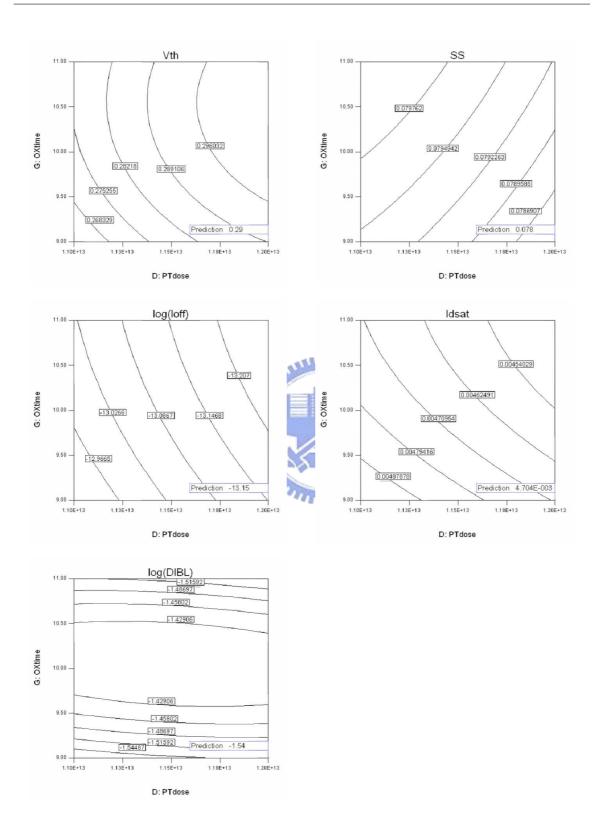
13.20

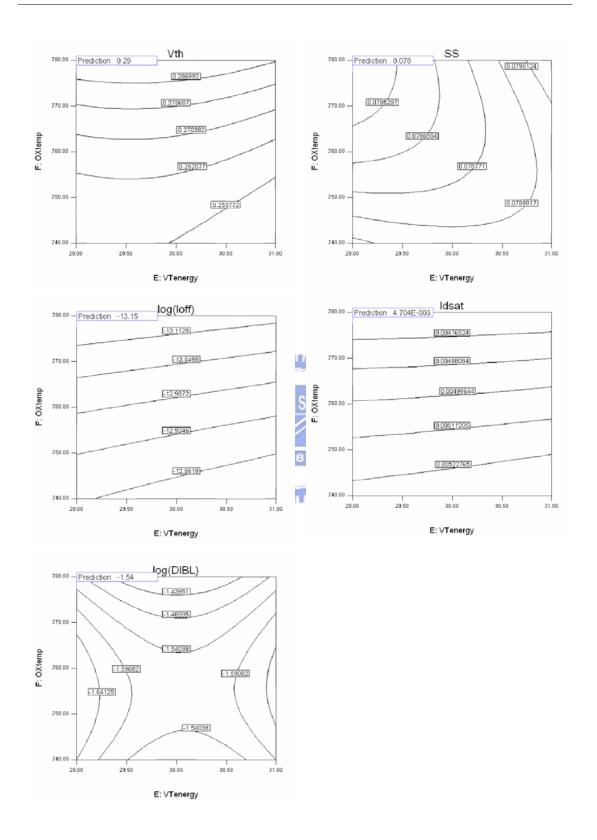
9.50

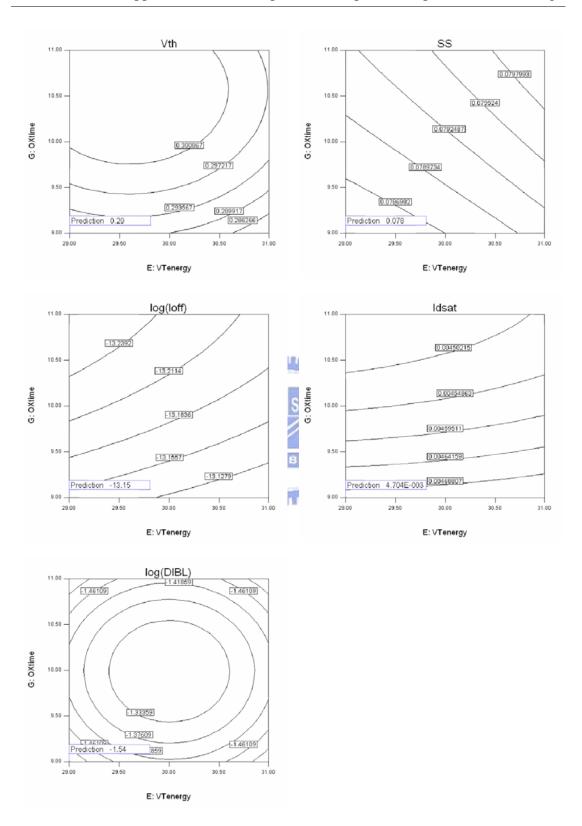
10.80

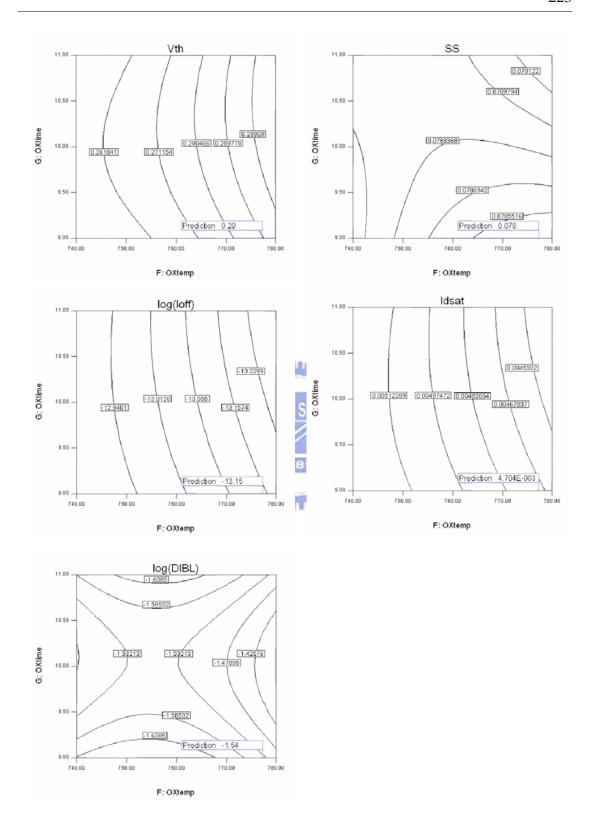














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Institute of Statistics	-1-2	

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